




Cite this: *RSC Adv.*, 2017, 7, 46406

A polystyrene/WO₃ opal composite monolayer film as a building block for the fabrication of 3D WO₃ inverse opal films

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Large area polystyrene (PS)/WO₃ opal composite monolayers were successfully fabricated *via* a modified “dynamic-hard-template” infiltration strategy. These composite monolayers were then used as building blocks for the synthesis of three-dimensional (3D) WO₃ inverse opal (IO) films in a bottom-up approach. To achieve this, a PS/WO₃ opal composite monolayer serves as a support upon which another PS/WO₃ opal composite monolayer is added, and so on, one over the other, rendering possible, after removal of the PS spheres template, the fabrication of large area 3D WO₃ IO films. Similarly, bilayer, and trilayer WO₃ IOs with large area, having the same pore sizes from layer to layer, can be obtained by repeatedly applying this strategy. This approach also allows control over hierarchical porosity and film thickness by simply changing the diameter of the sacrificial colloidal template and/or the inorganic precursor used in each layer. 3D WO₃ IO films fabricated with this technique exhibit good electrochemical reversibility, cycling stability, and increased coloration efficiency (CE) as the number of WO₃ IO layers is increased.

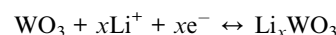
Received 14th August 2017
 Accepted 23rd September 2017

DOI: 10.1039/c7ra08998h

rsc.li/rsc-advances

Introduction

WO₃ is an important multifunctional material that has a wide spectrum of applications in electrochromic (EC) devices, catalysts, gas sensors, optical switching devices, *etc.*^{1,2} These applications are possible due to the structural flexibility of WO₃ and its cation intercalated states.^{3–5} Over the past three decades, intensive research has been carried out towards improving WO₃ based electrochromic (EC) devices.^{1,6–9} In a typical EC device, when a low voltage is applied between the transparent conducting electrodes, Li⁺ ions from the acting counter electrode and electrons (e[–]) from the other transparent electrode are injected into a transition metal EC layer inducing a color change. In the case of a WO₃ based device, this double injection results in the formation of Li_xWO₃ bronzes which coloration degree is controllable as a function the Li ion concentration. The process is usually represented by the following equation:



The performance of EC devices depends strongly on the microstructure, porosity, thickness, EC reversibility of the WO₃ layer, as well as its capability for accommodating guest ions (H⁺, Li⁺).^{1,6–9} Fabrication of three-dimensional (3D) ordered architectures have proved to be an effective mean to endow materials with enhanced or even novel properties.^{10–15} Extended efforts were made to realize such 3D ordered architectures by using strategies typically known as top-down route and bottom-up route. In contrast to top-down route, the bottom-up strategy, especially the one based on self-assembly of colloidal opal template, has attracted considerable interest for its scalable, time-saving, low-cost synthesis of nanoporous solid structures.^{16,17}

Conventionally, the synthesis of 3D ordered macroporous structure, that is 3D inverse opal (IO), involves three sequential steps: (1) growth or assembly of a colloidal opal crystal template; (2) infiltration of precursors into the colloidal opal template; (3) removal of the template to yield an inverse opal.^{6,18–22} Under such process, both the drying after self-assembly of the colloidal opal crystal template and the infiltration usually lead to cracks from uneven shrinkage, which consequently result in the unavailability of large scale IOs (<10 μm), thus limiting their applications.^{17,23} Efforts have been made to reduce/inhibit cracks through changing the precursors from sol-gel to nanoparticles,¹⁰ using vapor phase deposition,¹⁹ or *via* a co-assembly route,^{24,25} thus increasing the strength of the self-assembled

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templates.²⁵ These routes partly improved the 3D IO structures. From the standpoint of 3D colloidal opal growth, similar to the growing process of 'real' crystals, less ordered arrays formed firstly at the interface followed by an improvement of the periodic structure. After infiltration, drying and removal of the opal template causes great difference of shrinkage from the bottom layer to the top layer. As a result, cracks are unavoidable. The precursor phases are usually introduced into interstices between the template particles in the form of a liquid or vapor phase. Then, the colloidal opal composites undergo aggregation of the precursor particles and a discharge of excess side products (such as water, ethanol). Such diffusive process evolves from surface to center, that is, it starts from the top layer, moves to the second layer, and so on to the final or bottom layer. Correspondingly, shrinkage is different at the top layer as compared to that of the bottom layer, which results in the formation of important cracks. In comparison to colloid opal (3D opal) as starting template for infiltration of an inorganic precursor, 2D opals prepared by the floating route renders well-ordered monolayer opal composites as starting point. Then, one can build on this 2D opal, using it as substrate to add an additional 2D opal monolayer, and so on, repeating the process layer by layer, making possible the fabrication of a 3D 'defect-free' IO.^{26–28} For instance, Zhang *et al.* initially obtained a self-assembled monolayer PS colloidal crystal (MCC) over deionized water deposited on a glass slide.²⁷ After drying of the deionized water, the obtained PS MCC was transferred to a water surface. It was then picked up with an ITO substrate and then dried at 110 °C. Then it was irradiated in an ultraviolet ozone cleaner after which the tungsten precursor was drop casted over the PS MCC, resulting in a PS/WO₃ opal composite monolayer. After drying and annealing, a WO₃ IO film was obtained. This WO₃ IO film was subsequently used as substrate for the fabrication of a bilayer film by repeating the above described procedure.

Herein we propose an assembly route using PS/WO₃ opal composite monolayer as building block to yield 3D WO₃ IO films. Our technique differs from Zhang's in that it uses a limited number of steps. First an MCC is directly self-assembled on a water surface and an inorganic precursor is injected underneath the floating colloidal PS opal film. Then, the thus obtained floating PS/WO₃ opal composite film is deposited directly unto an ITO substrate. After proper drying, a 2D PS/WO₃ opal composite film is obtained. Making use of the hydrophilicity of the tungsten oxide well wrapped PS spheres from the resulting 2D PS/WO₃ opal composite film, a second PS/WO₃ opal composite layer can 'fix' onto the first, which is used as substrate, to build a second layer. By simply repeating once again the synthetic procedure, and after proper drying and removal of the PS template, a well ordered 3D WO₃ inverse opal can be obtained. Moreover, in this work, for the fabrication of multilayer films, a PS/WO₃ opal composite film is used as substrate whereas Zhang *et al.* used an already formed WO₃ IO film for this purpose. In addition, the infiltration of the organic precursor is done while the opal template is still floating on the water surface, which allows the tailoring of each single layer with a different dimensional structure as well as composition,

and the formation of multilayer WO₃ IO structures on any desired type of substrate, leading to new possibilities or new properties. The textural, structural, and optical features of the obtained WO₃ IO films were determined. The optimized IO films were used as active electrodes in the fabrication of electrochromic devices and their electrochromic properties were studied.

Experimental

Materials

The non-cross linked mono dispersed carboxyl polystyrene particles aqueous suspensions (PS particles, 530 nm in diameter, 5.0% w/v) were purchased from Spherotech Inc. Before using, they were diluted into 0.25% w/v with equal volume ethanol. ITO slides were sonicated in warm water, acetone, ethanol and deionized water for 15 min, respectively. Tungsten powder (12 μm, 99.9%) purchased from Aldrich. Tetrahydrofuran (THF), sodium dodecylsulfate (SDS), H₂O₂ (30%), and H₂SO₄ (98%) were analytically pure and were purchased from J&K Scientific and used as received without further purification. All the aqueous solutions were prepared with Millipore water (resistance = 18.2 MΩ cm⁻¹). The glass slides were immersed in a piranha solution (30% H₂O₂ : concentrated H₂SO₄ = 3 : 7, v/v) at 100 °C for 15 min, and then washed with Millipore water.

Synthesis of WO₃ colloidal solution

WO₃ colloidal solution was made by dissolving 3.8 g of tungsten powder in mixed solution of 36 ml H₂O₂ (30%) and 4 ml water. After the initial reaction for 20 minutes in ice-bath, the mixture was left to stir at room temperature for 20 hours to get a clear solution, and then refluxed at 100 °C for 2 h to get a transparent orange solution. Then, the solution was mixed with ethanol with the final volume ratio of water : ethanol = 7 : 3.

Fabrication of PS/WO₃ opal composite monolayer building blocks

The 2D PS/WO₃ opal composite monolayer building blocks were synthesized by "dynamic-hard-template" infiltration strategy as developed in our previous work.²⁹ Initially, a large area PS opal floating on surface of water was synthesized by gas-liquid-solid interface self-assembly method, as follows: a clean functionalized glass slide was placed on the bottom of a Petri dish ($\phi = 9$ cm). Then, Millipore water was added to barely submerge the slide. The pure PS particles suspension (0.4 ml, 0.25% w/v) was added drop-by-drop on the surface of the water, over the glass slide, in order to get a self-assembled monolayer of PS spheres on the water surface. Then, a few drops of 2 wt% sodium dodecylsulfate (SDS) solution were added into the water from a corner of the dish, to lower the surface tension, which packed the PS monolayer closely resulting in a 2D PS opal floating over the solution. Once the 2D self-assembly was achieved, the glass slide was gently removed.

After the formation of the PS opal monolayer, 6.5 ml of the WO₃ colloidal solution was injected into the water underneath the PS spheres. After the PS spheres and WO₃ colloidal solution



stabilized (about 15 min), an ITO substrate was introduced under the 2D PS opal composite film, and the water was sucked out to make the floating film sink onto the ITO substrate and form a 2D PS/WO₃ opal composite film. To obtain a 2D WO₃ IO film, the PS spheres template was removed by applying a THF treatment for 2 h, followed by heating at 150 °C for 30 min.

To form a bilayer WO₃ IO film, a previously formed 2D PS/WO₃ opal composite monolayer film on ITO was heat-treated at 65 °C overnight to allow the opal composite film to stick well to the ITO. This 2D PS/WO₃ opal composite monolayer was introduced as a substrate under a newly formed 2D PS/WO₃ opal composite monolayer floating on the water surface as previously explained. The water was sucked out to make the floating monolayer sink onto the substrate. The PS spheres template was removed by applying a THF treatment for 2 h and then the obtained film was heated at 150 °C for 30 min, yielding a bilayer WO₃ IO film. To form a trilayer WO₃ IO film, following the same sequence of treatment, the obtained PS/WO₃ opal composite bilayer film was then heated overnight at 65 °C to allow the newly formed PS/WO₃ composite layer to stick well to the underlying 2D PS/WO₃ opal composite monolayer film. Then it was introduced as a substrate under a newly formed 2D PS/WO₃ opal composite monolayer floating on the water surface, and the water was sucked out to make the floating monolayer sink onto the bilayer substrate. The PS spheres template was then removed by applying a THF treatment for 2 h and the obtained film was heated at 150 °C for 30 min, yielding a trilayer WO₃ IO film.

Electrochromic studies of the 2D and 3D WO₃ IO films

The optical transmittance behavior of the obtained monolayer, bilayer and trilayer WO₃ IO films on ITO substrates was studied during coloration and bleaching for applied potentials of ± 2.0 V. The measurements were conducted with a ECDs Cyclic Testing System (Zhuhai Kaivo Optoelectronic Technology Co., Ltd.) in which the working electrode consisted of the WO₃ IOs deposited on ITO substrates. The counter electrode was a platinum grid (25 \times 25 mm, 52 mesh, 0.1 mm in diameter). The electrolyte consisted of 0.1 mol L⁻¹ sulphuric acid (H₂SO₄).

Cyclic voltammetry (CV) of the obtained monolayer, bilayer and trilayer WO₃ IO films on ITO substrates was conducted using a Gamry Instruments Reference 3000 Potentiostat/Galvanostat/ZRA in a classical three-electrode electrochemical test cell filled with an electrolyte of 0.5 M LiClO₄ in dimethyl sulfoxide (DMSO) at a scan rate of 2 mV s⁻¹ and sweep potential between 1 V and -1 V. The WO₃ IO samples were vertically immersed into the electrolyte and acted as the working electrodes. A platinum wire and an Ag/AgCl/KCl electrode were taken as counter and reference electrodes, respectively.

Characterization

Morphologies of the films were studied using a field-emission scanning electron microscope (SEM, Hitachi S-570). The optical transmittance spectra were obtained using a PERSEETU-1810PC UV-vis-NIR spectrophotometer. The Raman spectra

were recorded at room temperature with an ALRS-5 Micro-Raman spectrometer.

Results and discussion

The synthesis process of 3D WO₃ IO films using PS/WO₃ opal composite monolayer films as building blocks, is described in Fig. 1. In short, water is first poured into a Petri dish. Then, PS spheres were spread on the water surface. The interaction forces among the spheres resulted in a well-ordered colloidal crystal monolayer over a large area floating over water.

A WO₃ aqueous-ethanol sol is then injected underneath the 2D PS spheres opal monolayer. Aided by the spreading action of ethanol, the dominant capillary forces from the interstitial space between the PS spheres attract the WO₃ sol which infiltrates the interstitial space. In the process, the space between the spheres is slightly enlarged but the relative positions of the spheres are hardly changed, thus preserving the opal structure. With this procedure, the PS spheres, being in an expandable liquid/air interface, have the freedom to accommodate guest materials. A PS/WO₃ opal composite monolayer structure floating over water is thus formed (Fig. 1(a)). Then, an ITO coated glass substrate is introduced underneath the floating PS/WO₃ composite monolayer (Fig. 1(a)).

Next, the water contained in the system is slowly sucked out in order to have the opal composite monolayer deposit onto the ITO substrate (Fig. 1(b)). After drying, a PS/WO₃ opal composite monolayer on ITO substrate is obtained (Fig. 1(c)). The thus obtained PS/WO₃ opal composite monolayer on ITO substrate was then used as building block on which a second floating PS/WO₃ opal composite monolayer was deposited (steps (e) to (f) of Fig. 1). Thereafter, the PS/WO₃ opal composite bilayer was used as building block for the fabrication of a trilayer PS/WO₃ opal composite film (steps (h) and (i) of Fig. 1). There are several advantages for this technique. First, this process takes only half an hour which is much faster than the conventional methods. Second, large-area PS/WO₃ opal composite films can be obtained without any special apparatus, and only a small amount of inorganic precursor is required for each experience. Finally, the PS/WO₃ opal composite films can be transferred to any kind of substrates regardless of surface wettability and smoothness.

WO₃ IO monolayer (Fig. 1(d)), bilayer (Fig. 1(g)), or trilayer (Fig. 1(j)) films were produced by applying a DHF treatment

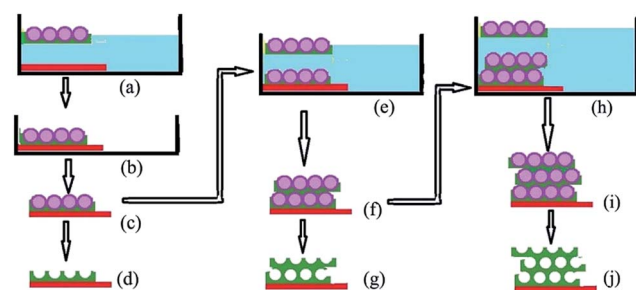


Fig. 1 Schematics of the assembly route for the fabrication of 3D WO₃ inverse opal films. Synthetic process for monolayer WO₃ IO (a–d); bilayer WO₃ IO (c, e, f, g); and trilayer (f, h, i, j).



after step (c), step (f) or step (i) of Fig. 1, respectively, as described in the experimental section.

Supported by the PS spheres during the formation of the multilayer PS/WO₃ opal composite, the WO₃ skeleton of the ordered array is retained after the removal of the PS template. As a result, all of the films show honeycomb structure with circular upper-end openings as can be seen from the SEM micrographs in Fig. 2(a)–(c) of three WO₃ IO films on ITO substrates, templated from 530 nm PS spheres, consisting of monolayer (1L), bilayer (2L), and trilayer (3L), respectively. However, a change in the WO₃ IO films can be seen as the number of layer is increased. Cow-nose-like porous array and trinacria form-like porous array were clearly observed in 2L and 3L IO films, respectively. The inner pores from the second layer in 3L are also apparent, which demonstrates that the porous network is interconnected throughout all three layers, allowing a good diffusion of guest materials. This is a major advantage for many potential applications since the accessibility and diffusion of chemical species within the structure is enhanced. From Fig. 2(a)–(c), it is also seen that the top openings of the three samples have nearly the same diameter (460 nm), smaller than that of the PS spheres template (530 nm), which indicates a corresponding lateral shrinkage of around 13% for all three samples, which is a little higher than earlier reports for multilayer IOs.^{10,24}

Fig. 2(d) shows cross-sectional SEM images of the 1L (top), 2L (middle), and 3L (bottom) WO₃ IO films on ITO substrates. The long-range horizontal ordering and virtual absence of defects in each layer is apparent. No collapse of the WO₃ walls was found for the bottom layers, this is due to the reduction of the number of steps involved in the fabrication of IO films and the use of room temperature during the fabrication process and removal of the PS spheres by chemical means instead of calcination. The absence of collapse among the different layers demonstrates the superiority of using a PS/WO₃ opal composite

as a substrate rather than a WO₃ IO film to build the subsequent layers. As a result, the thickness of the WO₃ IO increased from 305, to 694, to 916 nm for films 1L, 2L, and 3L, respectively. Considering half height infiltration for the top layer, such thickness is nearly proportional to the number of layers. Hence, the thickness of the films fabricated by this method can be precisely controlled, adding layers by simply repeating the 'Dynamic-hard-template' infiltration strategy.

Fig. 3 shows large area SEM images of the obtained monolayer (a), bilayer (b), and trilayer (c) WO₃ IO films. These low magnification images reveal crack-free monolayer films (Fig. 3(a)) and only microcracks, of the order of the PS spheres diameter or less, are seen in the bilayer (Fig. 3(b)) and trilayer (Fig. 3(c)) WO₃ IOs.

Raman spectra of the WO₃ IO films with various number of layers are displayed in Fig. 4. All the samples are amorphous tungsten oxide with the W=O stretching mode observed at about 965 cm⁻¹ and a broad band present between 600 and 875 cm⁻¹. Incidentally, amorphous and monoclinic WO₃ are the most common phases synthesized and studied as working EC cathodes in EC devices.⁵

The herein described route for the fabrication of multi-layer WO₃ IO films also adds versatility to the fabrication of hierarchical IO films as illustrated in Fig. 5, where it was used for the synthesis of a hierarchical WO₃ IO bilayer structure using 750 nm colloidal PS spheres for the bottom layer and 500 nm spheres for the top layer. Therefore, multilayer IO structures of different inorganic matrices with varying pore sizes could also be fabricated *via* repeated use of the herein described procedure. The resulting structures could have important applications in optical, photonic devices, hierarchical catalysis, *etc.*

Fig. 6 shows the UV-vis-NIR transmittance spectra of PS opal (monolayer) and PS/WO₃ opal composite (Fig. 6(a)), and WO₃ IO films (Fig. 6(b)) along with their corresponding optical reflection images (see insets). All samples show mainly blue color with different intensity levels revealing the corresponding photonic band gaps. In contrast to the PS opal monolayer, some blue shift appeared for the absorption of light from the three

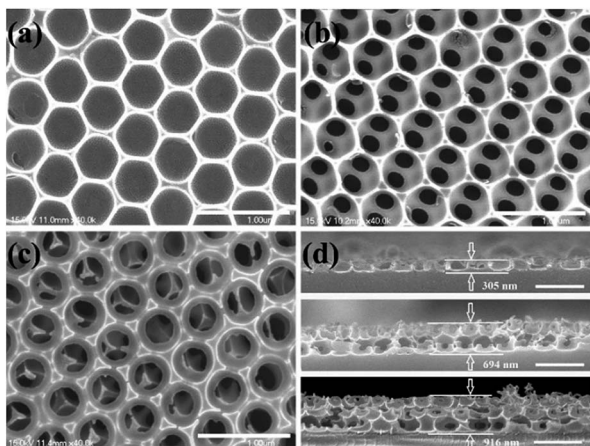


Fig. 2 Typical SEM images of WO₃ IO (a) monolayer (1L), (b) bilayer (2L), and (c) trilayer (3L) on ITO substrates after treatment in THF for 2 h followed by a heating at 150 °C for 30 min; (d) corresponding cross-section observations for monolayer (top), bilayer (middle), and trilayer (bottom). Scale bars: 1 μm.

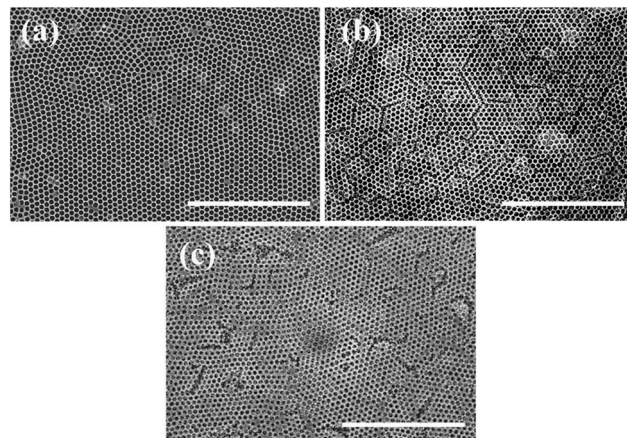


Fig. 3 Typical SEM image of monolayer (a); bilayer (b) and trilayer (c) WO₃ IOs in low magnification (scale bar: 10 μm).



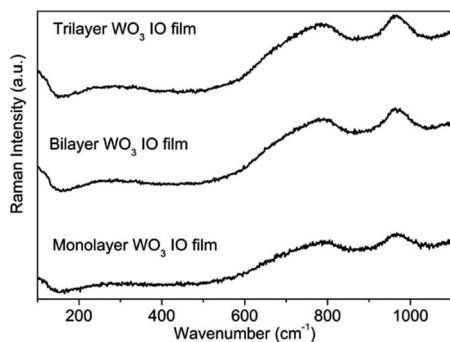


Fig. 4 Raman spectra of WO_3 IO films with various number of layers.

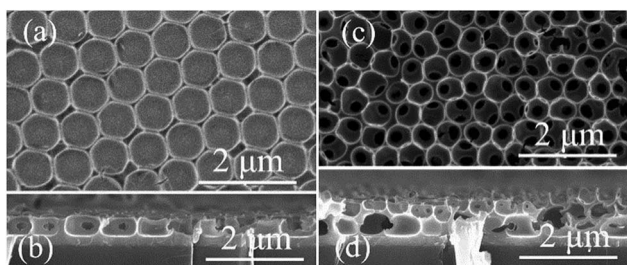


Fig. 5 SEM images of hierarchically porous WO_3 IO bilayer films synthesized from two different size PS spheres. Bottom IO layer templated from 750 nm (a) and top IO layer from 500 nm PS spheres (c) with corresponding cross-section image of bottom layer (b) and bilayer (d).

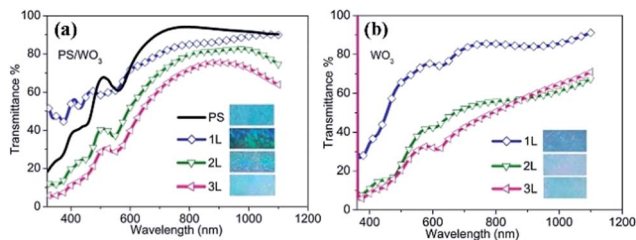


Fig. 6 (a) UV-vis-NIR transmittance spectra of PS opal monolayer film (solid line), PS/ WO_3 opal composite monolayer (diamond) 1L, bilayer (up-side triangle) 2L and trilayer (oblique triangle) 3L. (b) WO_3 IOs films, 1L (diamond), 2L (up-side triangle) and 3L (oblique triangle). Insets show the corresponding optical reflection images from PS opal monolayer, PS/ WO_3 opal composites and WO_3 IO films on ITO substrates taken on black background.

PS/ WO_3 opal composite films (around 550 nm for the PS/ WO_3 opal composite films as compared to 570 nm for the PS opal monolayer).

Apart from the absorption at 550 nm, there are several minor absorptions from 400 to 500 nm, contributing to the blue color at various levels. After the removal of the PS templates, a clear attenuation band in the transmittance spectra shown in Fig. 6(b) can be observed. However, the absorption shows a red-shift from 550 nm for the PS/ WO_3 opal composite films (Fig. 6(a)) to around 620 nm for the WO_3 IO films (Fig. 6(b)). Coupled with some minor absorption around 450 nm, a pale

pink doped main blue is observed in all three samples of WO_3 IOs. The transmittance of the IO films was 81.5, 65.6 and 53.3% at 700 nm wavelength for 1L, 2L and 3L, respectively, and 84.7, 80.6, and 67.0% at 1100 nm, for 1L, 2L and 3L, respectively.

The electrochromic behaviour of ITO-based WO_3 IO films with different number of layers was evaluated, and their optical transmittance spectra in colored and bleached states for applied potentials of ± 2.0 V are shown in Fig. 6(a) after 1 cycle, and in Fig. 6(b) after 10 cycles. The actual photographs of the WO_3 IO films in colored states are also presented as insets in Fig. 7. For cycle 1, in the bleached state, the transmittance of the films at a wavelength of 700 nm (Vis) was 80.8% for 1L, 74% for 2L, and 51.3% for 3L, whereas, at a wavelength of 1100 nm (NIR), the transmittance was 83.6% for 1L, 84% for 2L, and 69% for 3L. As shown in Table 1, when the coloration potential of 2.0 V is applied, the transmittance of the films at a wavelength of 700 nm is reduced and the films exhibited an optical contrast of 21.4, 32.1, and 31.7% for 1L, 2L and 3L, respectively. However, at a wavelength of 1100 nm the optical contrast for 1L remains practically unchanged (22.5%) as compared to that observed at 700 nm, for which wavelength it increased to 38.4 and 46% for 2L and 3L, respectively. This indicates a difference in optical absorption between the visible and IR regions as the number of layer is increased. It was also observed that the coloration became deeper for 2L and 3L samples after 10 cycles (Fig. 7(b)), which indicates that the coloration reactions keeps on going due to the diffusion effect. The optical contrast for 2L sample at 700 nm and 1100 nm reached 45.7% and 57.6%, respectively. For 3L though, a decrease in the optical contrast was observed at cycle 10 for both the visible and infrared regions as seen in Table 1.

Fig. 8 displays cyclic voltammograms (CV) recorded for the WO_3 IO films at a constant scan rate of 2 mV s^{-1} . The films exhibit a good electrochemical reversibility and cycling stability, which is reflected by the absence of shrinking in the peak current densities during all the cycles. The electrochromic performance of the WO_3 IO films was estimated by their coloration efficiency (CE) at a particular wavelength, defined by $\text{CE}(\lambda) = \Delta\text{OD}/q$, where ΔOD is the optical density change occurring in the film with lithium insertion and q is the charge inserted in the film. The charge is calculated from the CV of respective films.

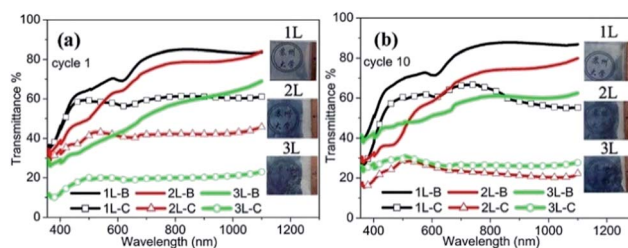


Fig. 7 Transmittance spectra of WO_3 IO films with different number of layers recorded at colored (C) (2.0 V, 10 s) and bleached (B) (-2.0 V, 10 s) states. The insets show typical photographs of the WO_3 IO films at the colored state, illustrating a distinct optical contrast. 1L, 2L and 3L refer to monolayer, bilayer and trilayer WO_3 IO films, respectively.



Table 1 Optical density variations of WO₃ IO films for cycle 1 and cycle 10

Sample	At 700 nm		At 1100 nm	
	ΔT^a (%)	ΔOD^b	ΔT^a (%)	ΔOD^b
Cycle 1				
1L	21.4	0.134	22.5	0.136
2L	32.1	0.247	38.4	0.265
3L	31.7	0.418	46	0.477
Cycle 10				
1L	16.9	0.0987	31.6	0.195
2L	45.7	0.470	57.6	0.554
3L	31.3	0.339	34.8	0.353

^a ΔT (%) at 700 nm (or 1100 nm) = $T_{\text{bleached}}(\%) - T_{\text{colored}}(\%)$. ^b ΔOD at 700 nm (or 1100 nm) = $\log(T_{\text{bleached}}(\%)/T_{\text{colored}}(\%))$.

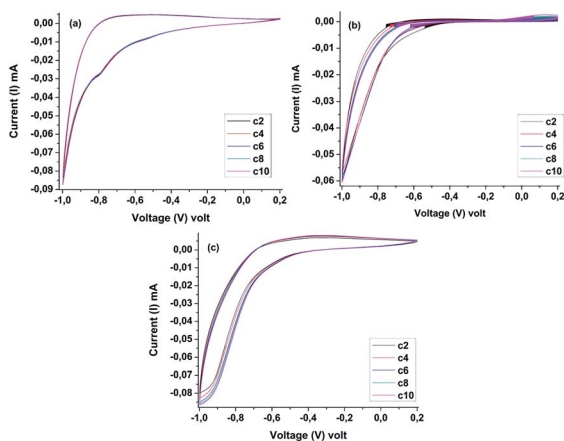


Fig. 8 Cyclic voltammograms (CV) of WO₃ IO films: monolayer (a), bilayer (b), and trilayer (c) obtained with 0.5 M LiClO₄ in dimethyl sulfoxide (DMSO) for 10 cycles at a scan rate of 2 mV s⁻¹.

The calculated CE for the first and tenth cycles at 700 and 1100 nm wavelengths of the WO₃ IO films are shown in Table 2. As seen in Table 2, CE is noticed to increase as the number of layer is increased, and tends to increase during cycling. Concurrently, the optical images of the WO₃ IO films (inset of Fig. 7) show an increased coloration as the number of layers is increased. These results thus render the WO₃ IO films suitable for practical electrochromic windows.

Sample 3L exhibits the highest CE of 40 cm² C⁻¹ at a wavelength of 1100 nm. The increase in CE with increasing number

Table 2 Coloration efficiency (CE) for WO₃ IO films with different number of layers

Sample	CE 1st cycle (cm ² C ⁻¹)		CE 10th cycle (cm ² C ⁻¹)	
	At 700 nm	At 1100 nm	At 700 nm	At 1100 nm
1L	8	13	10	15
2L	16	25	16	25
3L	19	31	24	40

of layers is related to the photonic effect as well as the increase in electrochromic material.

To the best of our knowledge, there are very few reports of WO₃ inverse opal film used as active electrode in EC devices. Nevertheless, the CE of 40 cm² C⁻¹ obtained for the 3L sample measured at 1100 nm compares favourably with a 3D ordered macroporous IO WO₃ film prepared by the conventional vertical convective self-assembly method reported by Badilescu *et al.*, in which CE was found to be 35 cm² C⁻¹.³⁰ Alsawafta *et al.* reported a higher CE of 70 cm² C⁻¹ for a macroporous WO₃ IO film doped with Au nanoparticles. However, they attributed this high result to the presence of the Au nanoparticles in the WO₃ IO film.³¹ Wei Cheng *et al.* reported CE values of around 21 cm² C⁻¹ for mesoporous WO₃ prepared from WCl₆ by a sol-gel method.³² Also, the present CE result of 40 cm² C⁻¹ exceeds the 25 cm² C⁻¹ of a pulsed laser deposited WO₃ film,³³ while for sputtered films CE is 34 cm² C⁻¹.³⁴ For sol-gel films deposited by dip-coating and heated at 150 °C, CE is reported to be 30 cm² C⁻¹.³⁵ Spin-coated sol-gel crystalline WO₃ films have CE of only about 20–25 cm² C⁻¹.³⁶ Thus, the CE results in this work for the 3L sample is higher than most of the values reported in the literature for pure WO₃ IO films.

Conclusions

In summary, three-dimensional highly ordered inverse opal films were designed and successfully fabricated by using PS/WO₃ opal composite monolayers obtained from a “Dynamic-hard-template” infiltration strategy as building block. We have demonstrated that WO₃ monolayer, bilayer and trilayer IO films, with the same pore size in each layer, can be obtained *via* repeated operations of the “Dynamic-hard-template” infiltration strategy. Furthermore, we have demonstrated the flexibility of the “Dynamic-hard-template” infiltration approach for the fabrication of multilayered hierarchical IO films by allowing a variation in macropore sizes and/or material from layer to layer. Due to the highly ordered macroporous texture, allowing an improved access of the electrolyte, the WO₃ IO films exhibit a good electrochemical reversibility, cycling stability, and increased coloration efficiency (CE) as the number of layers is increased. Thus, those WO₃ IO films could find promising applications in electrochromic windows, chemical sensors, and so on.

Conflicts of interest

There are no conflicts to declare.

Acknowledgements

The financial support of National Natural Science Foundation of China (grant #21301123), China Scholarship council, Priority Academic Program Development of Jiangsu Higher Education Institutions, the National Science and Engineering Research Council (NSERC) of Canada (grant #2017-05094), the John R. Evans Leaders Fund (Canada Foundation for Innovation) (grant #27741), and of the Research Assistantships Initiative of New



Brunswick Innovation Fund (NBIF) is gratefully acknowledged. We also greatly thank the help in micro-Raman characteristic from Tianjin Gangdong SCI&Tech. Development Co. LTD.

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